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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/935,002	08/21/2001	Tae-Pok Rhee	5484-92	9272	
20575	20575 7590 05/14/2004			EXAMINER	
	OHNSON & MCCOLL RRISON STREET	TSAI, I	TSAI, H JEY		
PORTLAND, OR 97205			ART UNIT	PAPER NUMBER	
			2812		

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)			
Office Action Summary		09/935,002	RHEE, TAE-POK			
		Examiner	Art Unit			
		H.Jey Tsai	2812			
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply						
THE - Exte after - If the - If NO - Failt Any	ORTENED STATUTORY PERIOD FOR REP MAILING DATE OF THIS COMMUNICATION nsions of time may be available under the provisions of 37 CFR of SIX (6) MONTHS from the mailing date of this communication. To period for reply specified above is less than thirty (30) days, a report of the provision of the	I. 1.136(a). In no event, however, may a reply be tired. Peply within the statutory minimum of thirty (30) day in the statutory minimum of thirty (30) day in the statutory minimum of thirty (30) day in the statutory minimum of thirty and statutory in the statutory of the statutory in the statutory of the stat	mely filed ys will be considered timely. In the mailing date of this communication. ED (35 U.S.C. § 133)			
Status						
1)	1) Responsive to communication(s) filed on					
2a) <u></u> ☐	This action is FINAL . 2b)⊠ Th	is action is non-final.				
3)□	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Disposit	on of Claims					
5)□ 6)⊠ 7)□	4) Claim(s) 1-51 is/are pending in the application. 4a) Of the above claim(s) 17-24 and 41-48 is/are withdrawn from consideration. 5) Claim(s) is/are allowed. 6) Claim(s) 1-16,25-40 and 49-51 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/or election requirement.					
Applicati	on Papers					
9) The specification is objected to by the Examiner.						
10) \square The drawing(s) filed on <u>21 August 2001</u> is/are: a) \square accepted or b) \square objected to by the Examiner.						
	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).					
11)	Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.					
Priority ι	ınder 35 U.S.C. § 119					
a)[Acknowledgment is made of a claim for foreig All b) Some * c) None of: 1. Certified copies of the priority documer 2. Certified copies of the priority documer 3. Copies of the certified copies of the priority application from the International Bureatee the attached detailed Office action for a list	nts have been received. Ints have been received in Application Ority documents have been received au (PCT Rule 17.2(a)).	on No ed in this National Stage			
Attachmen	i(s)					
	e of References Cited (PTO-892)	4) Interview Summary				
3) 🔲 Inform	e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449 or PTO/SB/08 · No(s)/Mail Date	Paper No(s)/Mail Da 5) Notice of Informat Page 6) Other:	atent Application (PTO-152)			

Application/Control Number: 09/935,002

Art Unit: 2812

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-16, 25-40 and 49-51 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sundaram et al. 5,372,967 in view of Yamada et al. 6,236,538, both are previously applied, and Lue 5,863,806, newly cited.

The reference(s) teach the features:

Sundaram et al. substantially discloses a method of forming an inductor on the semiconductor device, which includes:

forming a groove with a spiral shape or other shapes in the insulating layer 11, fig. 4+,

forming a conductive layer 18 on the groove,

forming cylindrical insulator 19, col. 3, lines 18+,

forming upper conductive lines 23 contacting the underlying conductive layer 18 to form an inductor, figures 5 and 6.

The difference between the reference(s) and the claims are as follows: Sundaram et al. teaches forming an inductor with a cylindrical insulator formed in the groove of insulating layer but does not teaches semicircle groove and cylindrical insulator formed over the groove.

However, Yamada et al. teaches forming an inductor in the semicircle grooves in figures 35 and

Art Unit: 2812

36 in the insulating layer 1a, 1b, or 41 (since substrate 1 is semicircle, hence, layer 41 inherently a semicircle), a conductive layer 21 and an inductor core 31 and upper conductive line 22 to form an inductor, see col. 25, lines 15+ and figures 1+. And, Lue teaches at fig.1-2 and col. 2, lines 47+, forming lower conductive lines 36 on the groove, the lower conductive lines 36 spaced apart from each other, see fig. 1, growing the oxidizable material layer by oxidation to form a cylindrical insulating layer 38 in the groove such that an upper portion of the cylindrical insulator protrudes from an upper surface of the groove, forming upper conductive lines 48 on the insulator 38/44 to be in contact with the underlying lower conductive lines 36.

It would have been obvious to one having ordinary skill in the art at the time the invention was made to have recognized that Sundaram et al's spiral shape groove can be a semicircle groove after etching the insulating layer as suggested by Yamada et al. And cylindrical insulator can be formed over the groove with rounded shape in the upper surface as taught by Lue because the bottom of groove become rounded during the etching of insulating film so that a semi-circle groove is formed and the material increases volume during oxidation so that cylindrical insulator is formed over the surface of the groove.

Applicant's arguments filed on March 1, 2004 have been fully considered but they are not persuasive. Because Sundaram et al. clearly teaches forming cylindrical insulator 19, col. 3, lines 18+ and fig. 5 and groove is a spiral shape, hence, from figs. 4-5, the groove is a semicircle with a cylindrical insulator formed inside. And, Yamada also teaches a semicircle groove in figs. 35A and 35B with insulator inductor core 1a, 1b or 41 formed inside. And, Lue teaches at fig.1-2 and col. 2, lines 47+, a cylindrical insulator formed in the groove and over the groove with rounded shape.

Application/Control Number: 09/935,002

Art Unit: 2812

Any inquiry of a general nature or clerical matters or relating to the status of this application or proceeding should be directed to the customer service whose telephone number is (703) 308-4357 and Fax number (703) 872-9306.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to H. Jey Tsai whose telephone number is (703) 308-1374. The examiner can normally be reached on from 7:00 Am to 4:00 Pm., Monday thru Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John Niebling can be reached on (703) 308-3325. The fax phone number for this Group is (703) 872-9306.

hjt

5/4/04

H. Jey Tsai Primary Examiner Patent Examining Group 2800